

Versatile Strategy for Electrophoretic Deposition of Polyvinylidene Fluoride-Metal Oxide Nanocomposites

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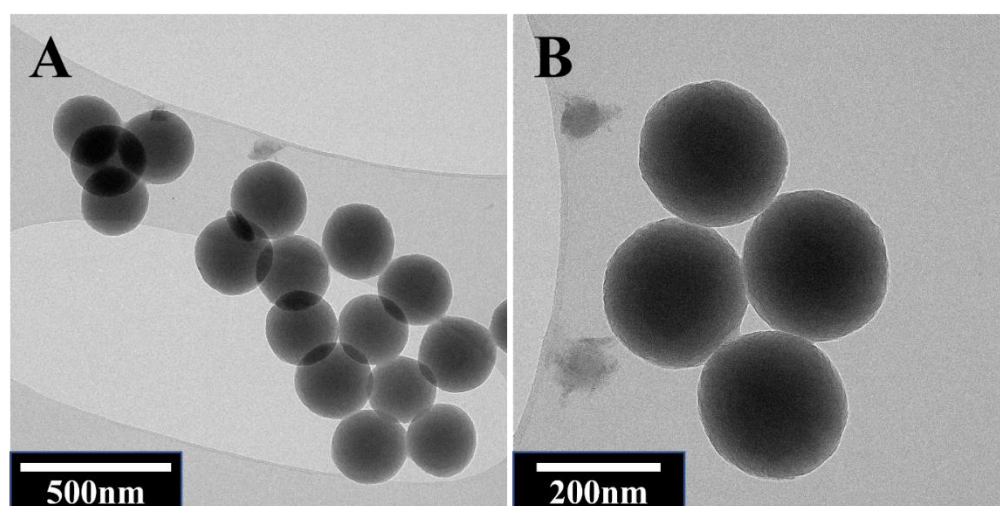


Figure S1. TEM images at different magnifications of as-received PVDF particles.

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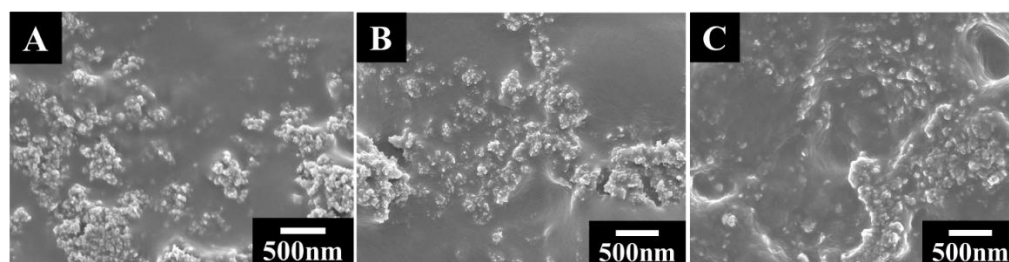


Figure S2. SEM images of films, prepared from 5 g L^{−1} PVDF solutions, containing (A) 1 g L^{−1} CA and 1 g L^{−1} MnO₂, (B) 1 g L^{−1} CV and 1 g L^{−1} TiO₂, (C) 1 g L^{−1} CV and 1 g L^{−1} NiFe₂O₄ at a deposition voltage of 50 V annealed at 200°C.